

Species and Pathways in a He/NO Plasma

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Abstract: We quantify the stable and radical species present in a radiofrequency (RF) atmospheric pressure He/NO plasma based on molecular beam mass spectrometry (MBMS) measurements. Our findings show that NO is mainly reduced to form N₂ and O₂ but may also be oxidized to form small amounts of NO₂, depending on the initial NO density. NO₂ formation is expected to occur via reactions involving short-lived species such as O.

1. Introduction

Fossil-fuel-powered vehicles contain catalytic aftertreatment systems for remediation of NO_x pollutants, however, selective catalytic reduction of NO_x is kinetically limited below 473 K [1]. Such limitations lead to the “cold-start” problem, where temperatures are not high enough for effective NO_x reduction during vehicle start-up. We plan to employ low-temperature plasma in series with a catalyst to allow NO_x reduction to proceed at non-equilibrium conditions.

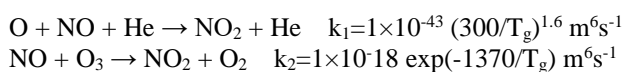
As a precursor to studying NO_x reduction via plasma catalysis, we have focused on identifying and quantifying the species produced in the plasma phase. Here, we report how varying the initial concentration of NO impacts the species formed in a He/NO plasma.

2. Methods

An RF atmospheric pressure plasma jet is used to generate the He/NO plasma. MBMS measurements are taken at the outlet of the plasma jet. Species densities are quantified for NO, NO₂, N₂, O₂, and O with reference to calibration [2]. N, N₂O, and O₃ were detected as well but were not present in measurable quantities. NO concentration is varied from 20-200 ppm.

3. Results and Discussion

Figure 1 shows that as initial NO density increases, NO consumption and N₂ and O₂ production increase. This trend is expected because higher NO densities are expected to increase the rate of reactions that decompose NO. Figure 1 shows a discrepancy between the amount of N₂ and O₂ produced, which would be approximately equal if N₂ and O₂ were the only products formed. For each of the conditions shown, O was quantified; and for the 50, 100, and 200 ppm NO cases, NO₂ was quantified. The formation of O and NO₂ can account for the difference between N₂ and O₂ densities. The increase in NO₂ density with increasing initial NO density implies that increasing initial NO concentration increases the rate of NO₂ formation pathways until detectable levels of NO₂ are formed. Two potential pathways leveraging non-charged reactive species for NO₂ formation are as follows [3]:



The gas residence time in the plasma and afterglow is 1.2 ms, therefore, stable species like O₃ are unlikely to

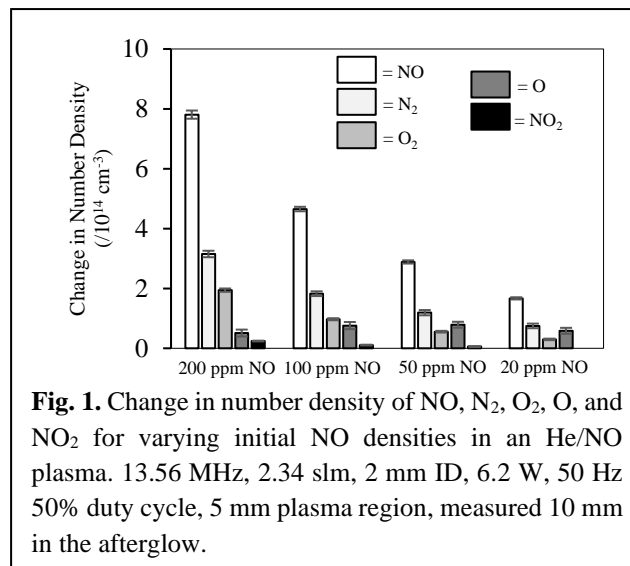


Fig. 1. Change in number density of NO, N₂, O₂, O, and NO₂ for varying initial NO densities in an He/NO plasma. 13.56 MHz, 2.34 slm, 2 mm ID, 6.2 W, 50 Hz 50% duty cycle, 5 mm plasma region, measured 10 mm in the afterglow.

contribute to NO₂ formation due to the lower reactivity of such species. Rather, short-lived species like O are expected to contribute to NO₂ formation. Future work will include varying gas flow rates in the reactor to determine the range of timescales over which NO₂ formation occurs. These timescales will be compared with timescales of NO₂ formation reactions from the literature, including reactions with charged species, to determine reaction pathways.

4. Conclusion

The stable and radical species formed and consumed in a He/NO plasma were quantified, and potential NO₂ formation pathways were presented. N₂ and O₂ were the main products formed, while NO₂ was generated in small amounts for conditions with a higher initial NO density. NO₂ formation is expected to occur via reactions involving short-lived species like O with lifetimes on the same scale as the gas residence time in the reactor.

Acknowledgement

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References

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- [3] He et al. *PSST* **2021**, 30 (10), 105017.